

Hysteresis loops of magnetoconductance in graphene devices

Andrea Candini^{1*}, Christian Alvino^{1,2},
Wolfgang Wernsdorfer³ and Marco Affronte^{1,2}

¹Centro S³, Istituto Nanoscienze – CNR, Modena, Italy

²Università di Modena e Reggio Emilia, Modena Italy

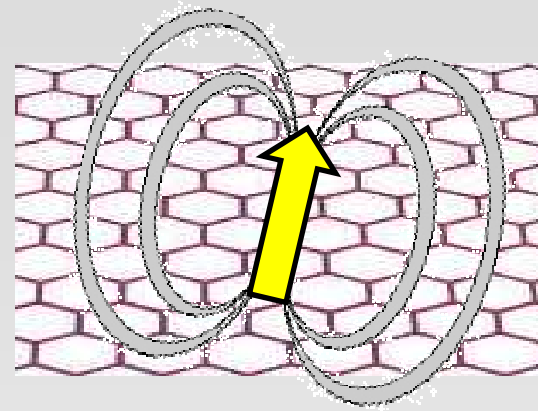
³Institut Néel CNRS, Grenoble, France



* andrea.candini@nano.cnr.it

Introduction

Magnetism in graphene



Theory

- Vacancies
- H adatoms
- Metal adatoms
- Edges

Experiments (see also next talk)

Ferromagnetism in defected HOPG (Esquinazi *et al.* PRL 91, 227201 2003)

Magnetism of single vacancy (Ugeda *et al.* PRL 104, 096804 2010)

Ferromagnetism in graphene (Wang *et al.* Nano Lett. 9, 202 2009)

Paramagnetism in graphene (Sepioni *et al.* PRL 105, 207205 2010)

Introduction

...however... No evidence from magnetotransport

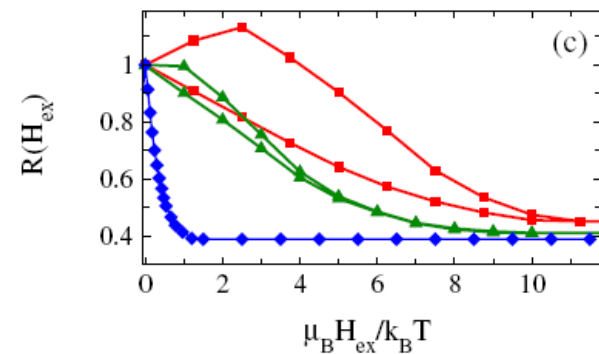
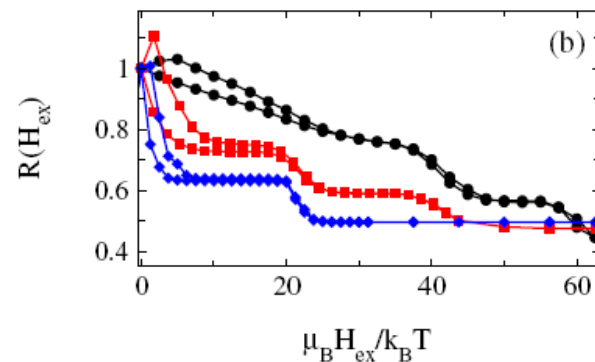
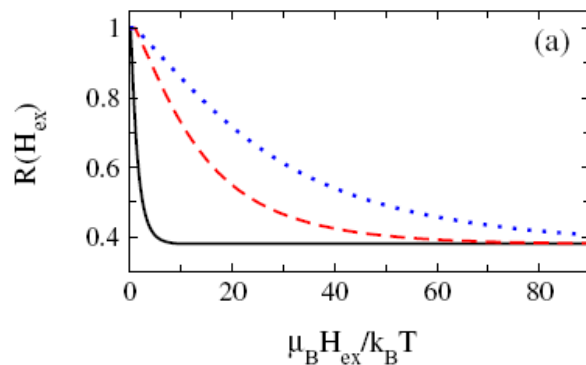
Large number of data available

“Prediction” of visibility

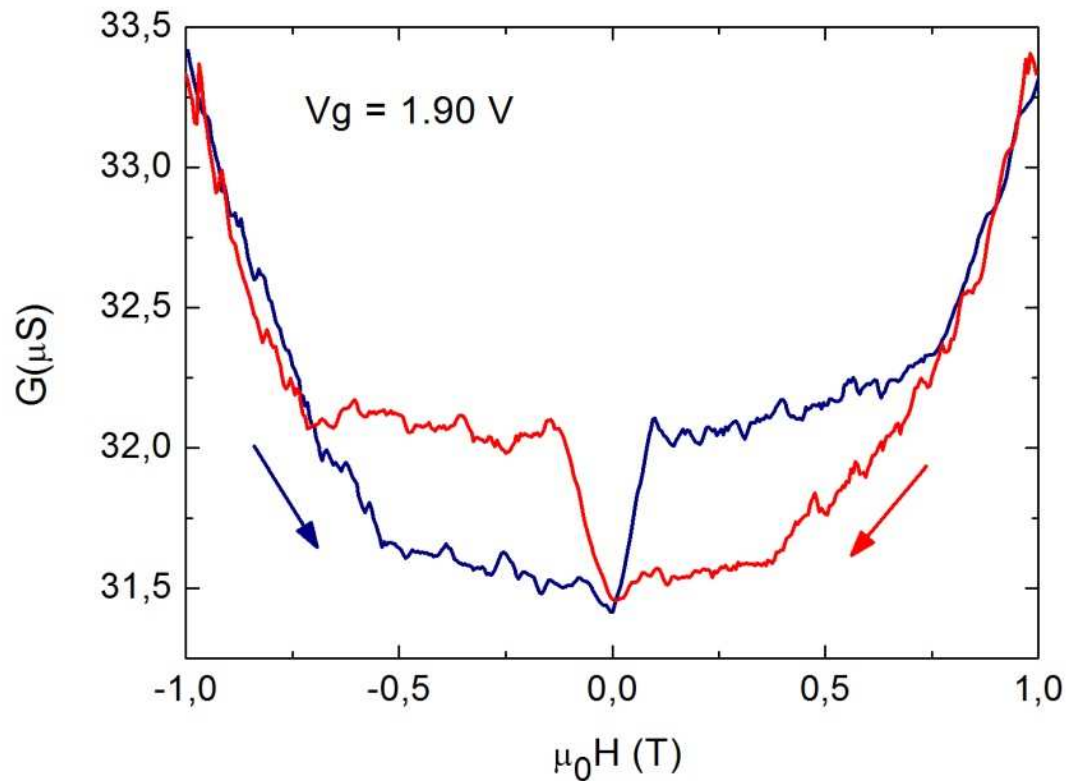
PHYSICAL REVIEW B 80, 245408 (2009)

Magnetism and magnetotransport in disordered graphene

T. G. Rappoport,¹ Bruno Uchoa,² and A. H. Castro Neto³



Introduction



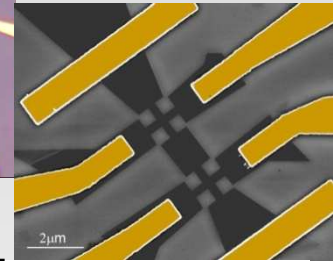
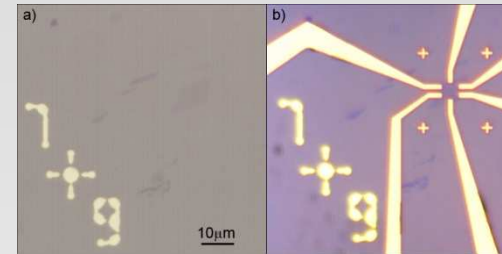
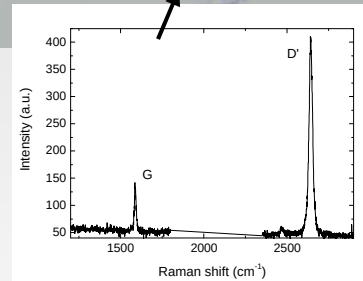
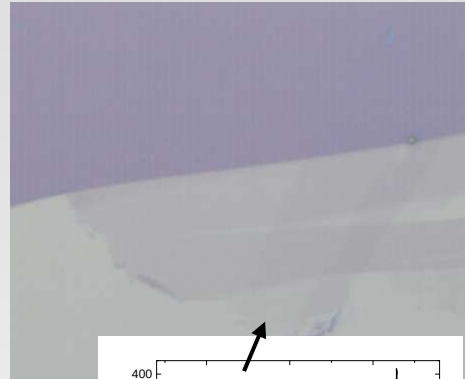
In-plane field

$T = 0.04 \text{ K}$

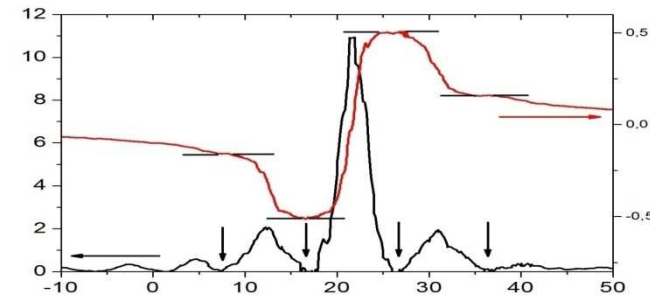
Sweep rate = 0.05 T/s

Candini *et al.* PRB 83 121401(R) 2011

Fabrication of Graphene Devices

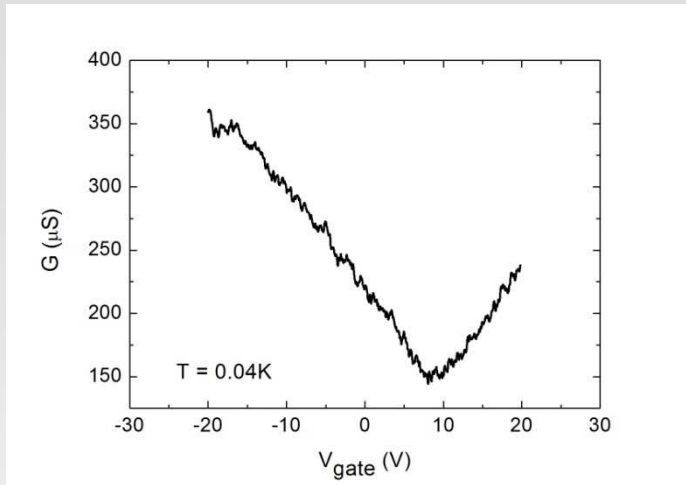


Quantum Hall Effect



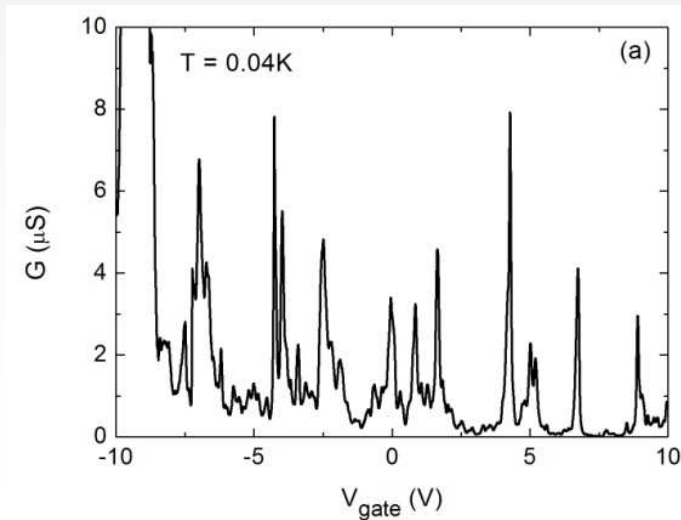
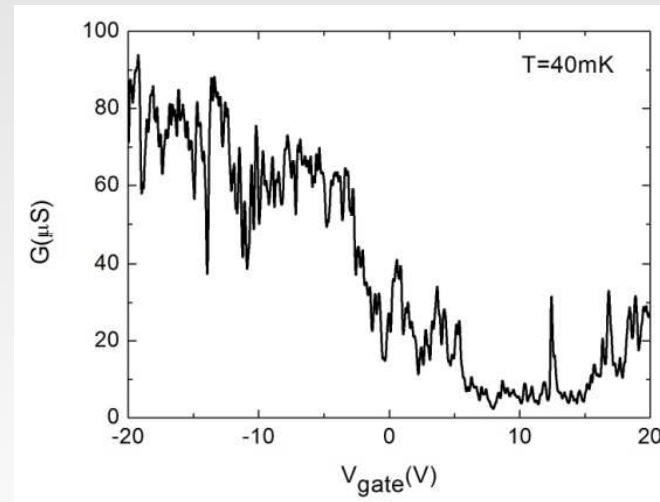
- Graphene obtained by the Scotch-tape method
- Characterization by micro-Raman spectroscopy
- Electron Beam Lithography to define contacts and to etch devices
- Devices of good quality (observation of Quantum Hall effect)

Device size



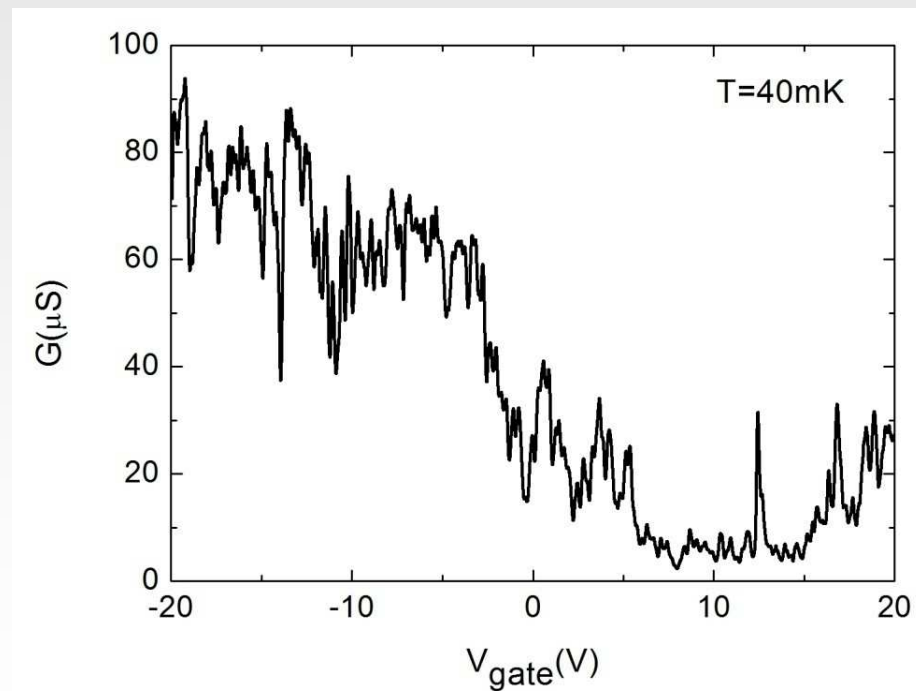
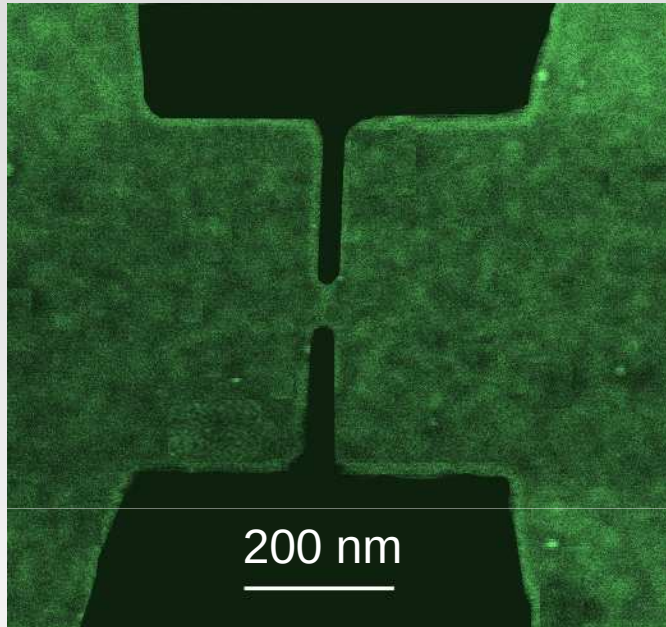
Unetched devices
 μ up to $5000 \text{ cm}^2/\text{Vs}$

Constriction $\sim 60\text{nm}$



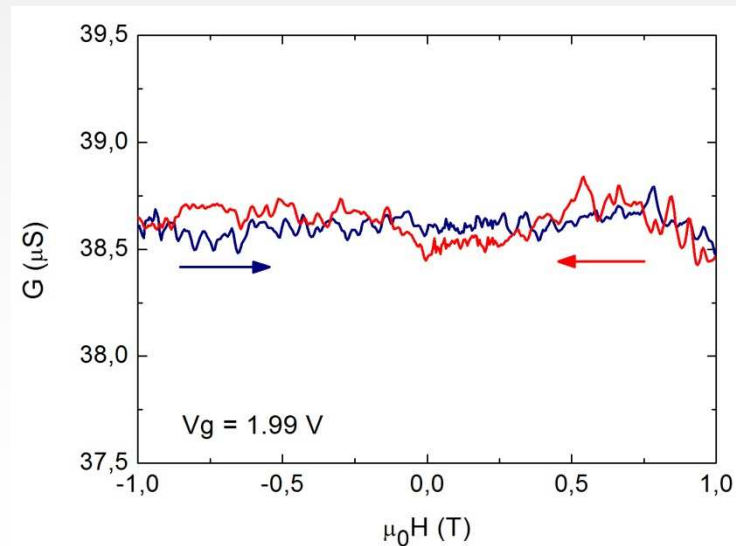
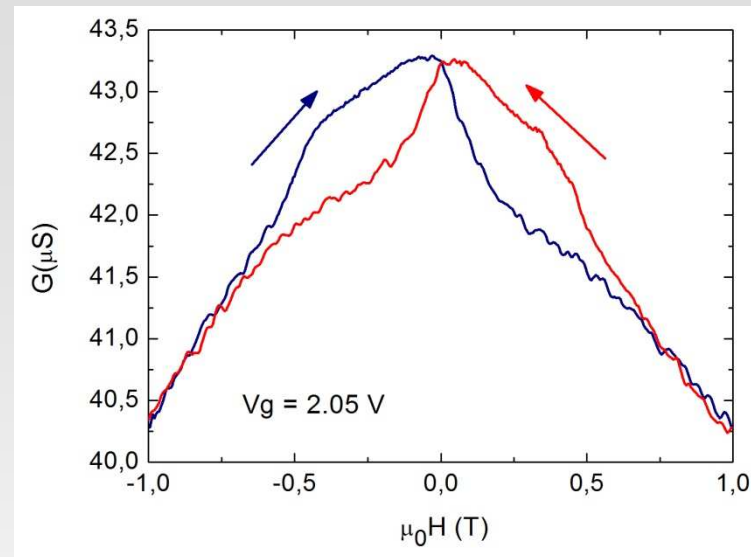
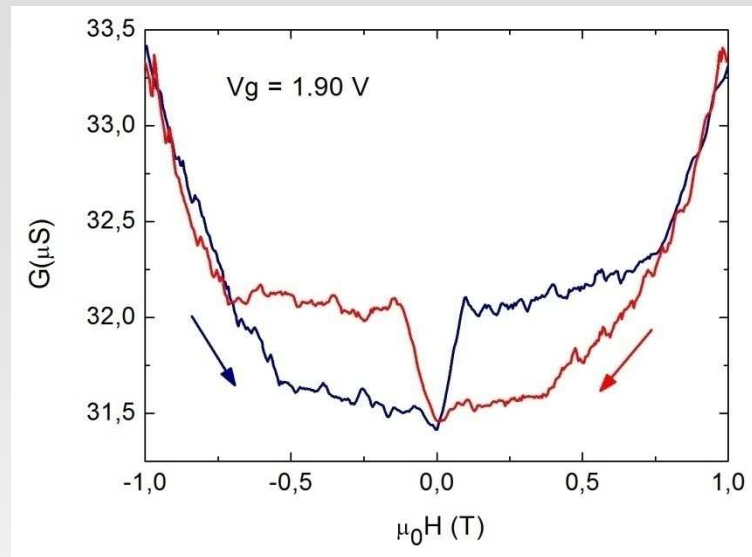
Constriction $\sim 30\text{nm}$

Sample characterization



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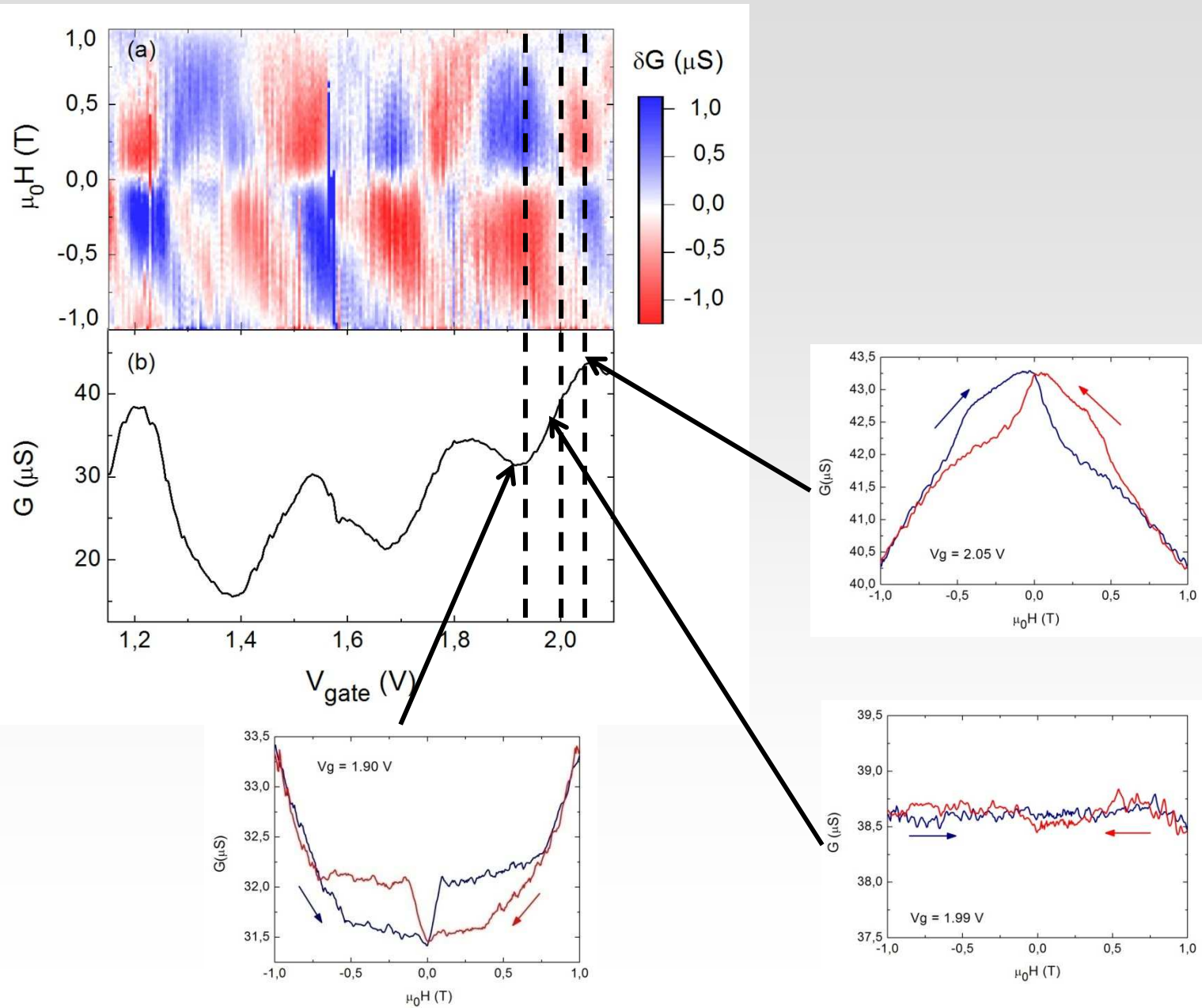
Magneto-transport



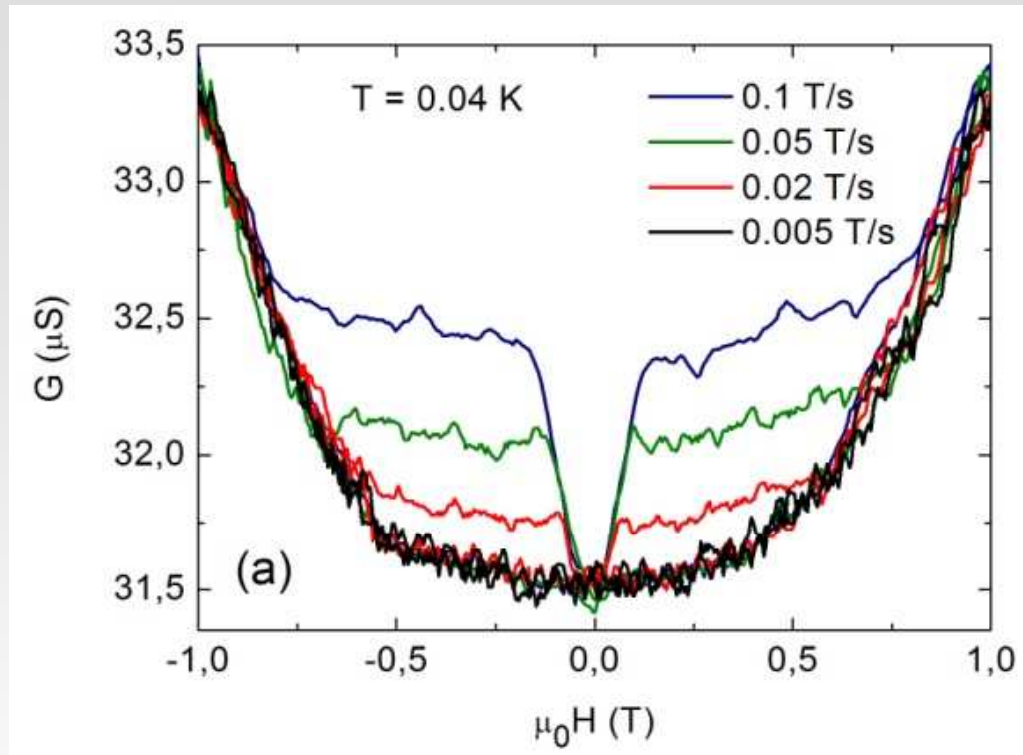
$T = 0.04$ K

Sweep rate = 0.05 T/s

Gate-dependence



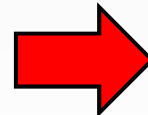
Field sweep rate dependence



The hysteresis disappears
for slow sweep rates

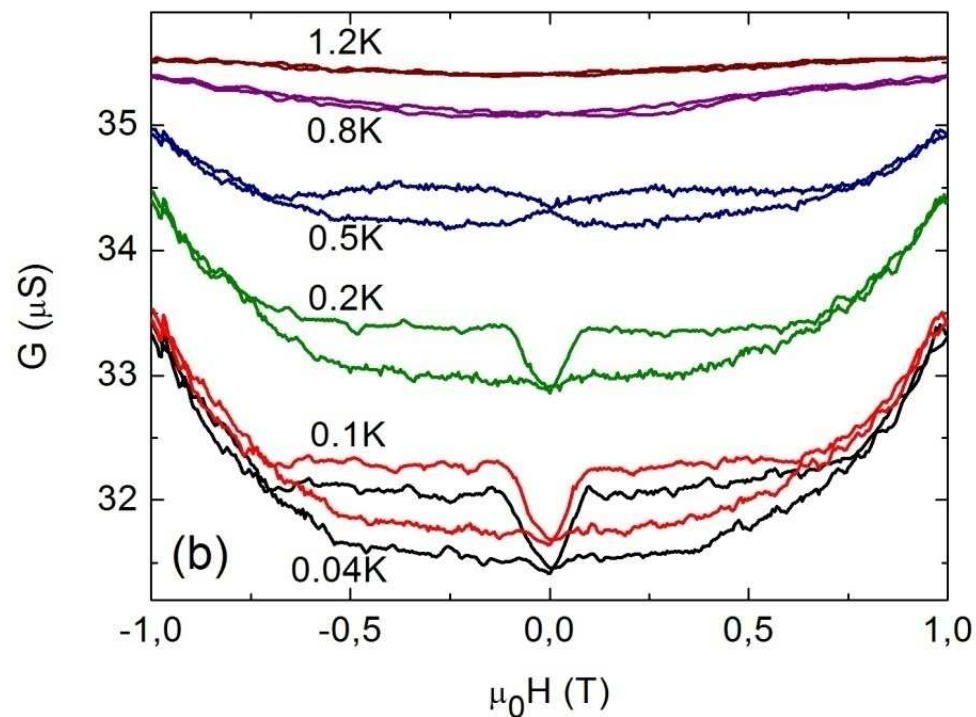
The (non-hysteretic)
magnetoconductance is still
present

Magnetoconductivity



Non hysteretic part
(gate dependent)
+
Hysteretic part

Temperature dependence

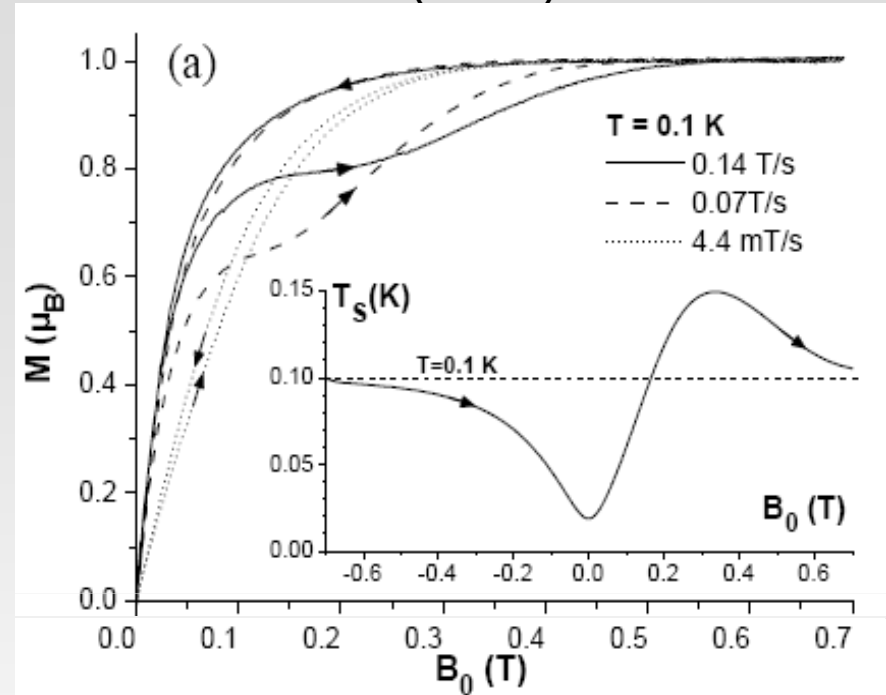
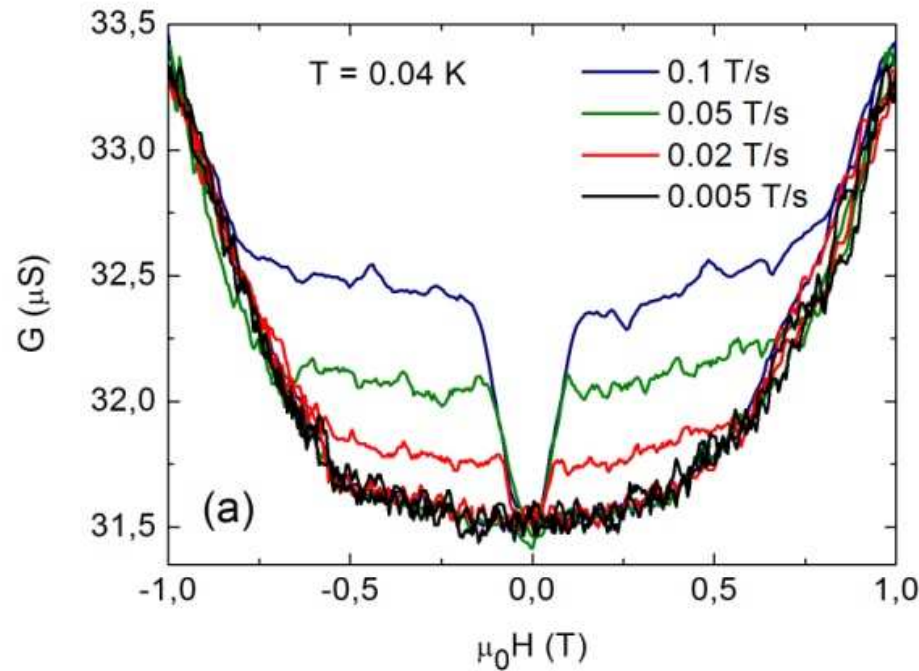


The hysteresis disappears only above $\sim 1K$

It disappears only when the (non-hysteretic) magnetoconductivity becomes flat

Explanation

I. Chiorescu *et al*/ PRL 84, 3454 – 3457 (2000)



Magnetic signal from paramagnetic spin moments

Hysteresis appears in the **phonon-bottleneck** regime
(low temperature, fast field sweep rate)

Candini *et al.* PRB 83 121401(R) 2011

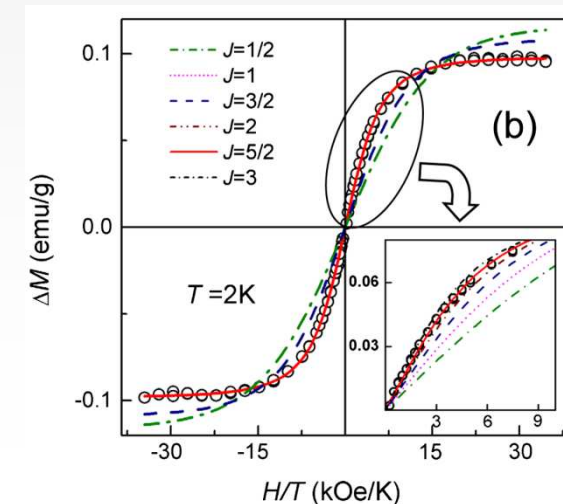
Explanation

- ➔ Presence of (para)magnetic impurities
- ➔ Their magnetization reversal is sensed by the conduction charges

Hysteresis is suppressed for $T > 1\text{K}$ and $H_t > 0.5\text{T}$

➔ **$S > 1/2$**

Agreement with
Sepioni et al. PRL 105 207205 2010



Origin of magnetic impurities

Vacancies / (Passivated) intrinsic defects

Metal adatoms / adsorbates *unwanted*

~~H - adatoms~~ No dependence on annealing

~~Edges~~ No dependence on the size or etching

Conclusions

Observation of hysteresis loops of the (in plane) magnetoconductivity in graphene devices at low temperatures and fast field sweep rate

True for different sizes and transport regimes

Magnetization reversal of spin moments in graphene (probably defects) with $S > 1/2$

Thanks to

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